



IPW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:	§	
Pei-Yang Yan	§	Art Unit: 1756
	§	
Serial No.: 10/631,171	§	Examiner: Stephen D. Rosasco
	§	
Filed: July 31, 2003	§	Docket: ITL.0952US
	§	P15976
For: Multilayer Reflective Extreme	§	
Ultraviolet Lithography Mask Blanks	§	Assignee: Intel Corporation
	§	

Mail Stop **Amendment**  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**REPLY TO PAPER NO. 20050420**

Sir:

In response to the office action mailed May 5, 2005, reconsideration is requested in view of the following remarks.

Date of Deposit: June 30, 2005  
I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as **first class mail** with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.  
*Cynthia L. Hayden*  
Cynthia L. Hayden